NAVY Armada <13068>

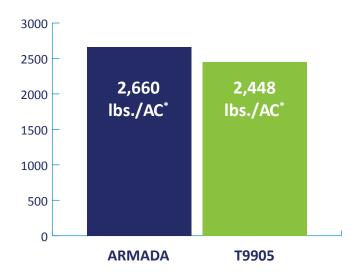


New navy with improved architecture and good dry down!

PROFILE

Navy Armada <13068> is a broadly adapted navy bean variety ideally suited to Minnesota, Michigan, and Ontario production regions. A consistent performer throughout the trialing process and in commercial production, its upright architecture, high pod set, and excellent yield potential make it an excellent choice for direct harvesting and conventional growers.

Assuming the 200 lbs./AC* yield increase over T9905, profit would increase \$60/AC on \$30/cwt beans. This would amount to \$6,000 increased profit over T9905 on 100 acres of production while only maturing out 2 day later than T9905**.



- * Yield data based on 20 yr./locations of data.
- ** Maturity data is based on 12 yr./locations of data.
- *** Seed count data is based on 7 yr./locations of data. Data from 2014 - 2019 with trials in Bay, Huron, Sanilac, Tuscola, Pigeon, Ruth and more.



TRIAL DATA

ARMADA

- Excellent upright architecture suitable for direct harvest.
- Armada <13068> has demonstrated good canning characteristics.

Approx. Maturity

Matures 101-105 days or about 2 day's later than T9905**

Approx. Seed Count

2,044 sds./lb. as compared to T9905 at 2,013 sds./lb****

Disease Resistance

Armada <13068> has the "I" gene for bean common mosaic virus shown similar resistance to rust as HMS Medalist in the CSU rust trials.

TO PURCHASE SEED:
CONTACT YOUR LOCAL DEALER

For customers around the world, ADM draws on its resources—its people, products, and market perspective—to help them meet today's consumer demands and envision tomorrow's needs.



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NA Armada <13068> was developed through ProVita, Inc.'s navy breeding program for ADM - Seedwest and is being marketed and sold by AmeriSeed and ADM - Seedwest in the Great Lakes region.

NA Armada <13068> PVP protection is applied for Unauthorized propagation of this variety is prohibited.

All variety information presented herin is based on field and laboratory observations. Actual crop yield and quality are dependent upon many factors beyond our control. Since environmental conditions and local practices may af-fect variety characteristics and performance, we disclaim legal responsibility therefor. Read all tags and labels. They contain important conditions of sale, including limitations of warranties and remedies.

KEY TO RESISTANCE ABBREVIATIONS FOR BEANS

Plant Type 1A	Bush determinate erect stem
Plant Type 2A	Erect growth indeterminate short runners
Plant Type 2B	Erect growth indeterminate with medium to long runners
Plant Type 3B	Prostrate vine indeterminate growth with long runners
BCMV	Bean common mosaic caused by the specified strains of Bean common mosaic virus
BCTV	Curly top caused by Beet curly top virus
BGYMV	Bean golden yellow mosaic caused by Bean golden yellow mosaic virus
CI	Anthracnose caused by Collectrichum lindemuthianum
Psp	Halo blight caused by Pseudomnas savastanoi pv. phaseolicola
Pss	Bacterial brown spot caused by Pseudomaonas syringae pv. syringae
Ua	Rust caused by the specified races of Uromyces appendiculatus
HR	High Resistance: describes plant varieties that highly restrict the growth and development of the specified pest or pathogen under normal pest or pathogen pressure when compared to susceptible varieties. Highly resistant varieties may, however, exhibit some symptoms or damage under heavy pest or pathogen pressure.
IR	Intermediate Resistance: describes plant varieties that restrict the growth and development of the specified pest or pathogen, but may exhibit a greater range of symptoms or damage compared to highly resistant varieties. Intermediately resistant varieties will still show less severe symptoms or damage than susceptible plant varieties when grown under similar environmental conditions and/or pest or pathogen pressure.

In cases where specific races or strains are not noted the variety is resistant to some, but not necessarily all known races or strains of the pathogen.

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